

Towards less than 10 mg/Wp silver consumption in HJT modules with ECA based interconnection

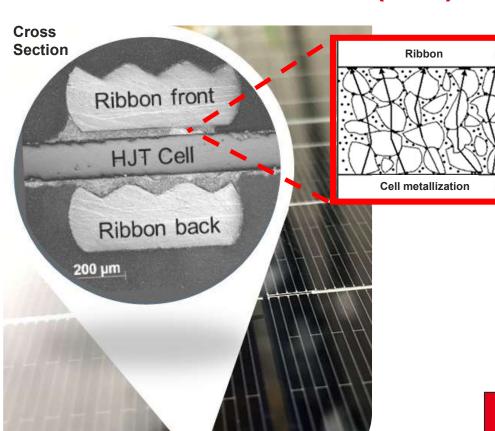
<u>Rémi Monna</u>, Gustavo Rodrigues Lopes, Nathalie Ronayette-Lamoine, Laurent Fonteneau, Anne-Sophie Ozanne, Jules Clerjon, Didier Therme, Johann Jourdan, Bertrand Hladys





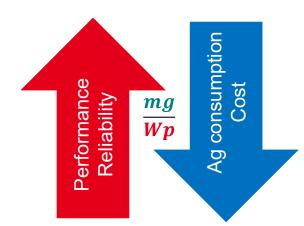
Cell interconnection for HJT cells made with Electrically

Conductive Adhesives (ECA)



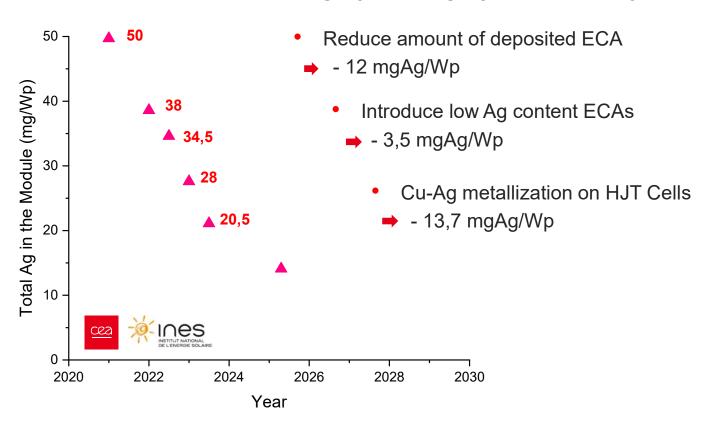
- ✓ Lead and Bismuth free technology
- ✓ Low T° process and wide window (80 200°C)
- ✓ Compatibility with temperature sensitive cells like HJT and Si-Perovskite tandem cells

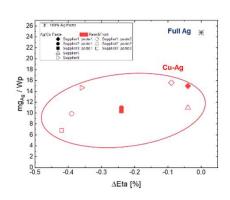
Continue to reduce Ag consumption while maintaining **PERFORMANCE** and **RELIABILITY**



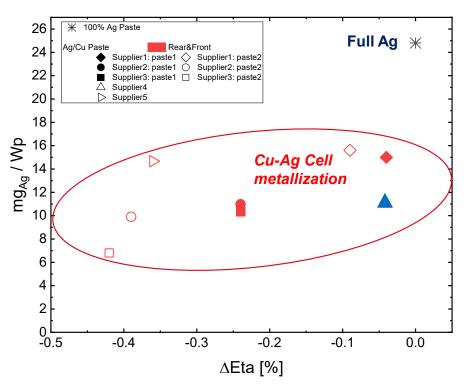
Radical reduction of silver is a must for TW scale manufacturing in PV Our target < 3 mg/Wp by 2030



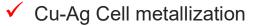




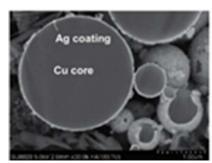




A.Lanterne & al : Copper-based Metallization Approaches for Drastic Reduction of Silver Content in Heterojunction Solar Cells – PVSEC 2024

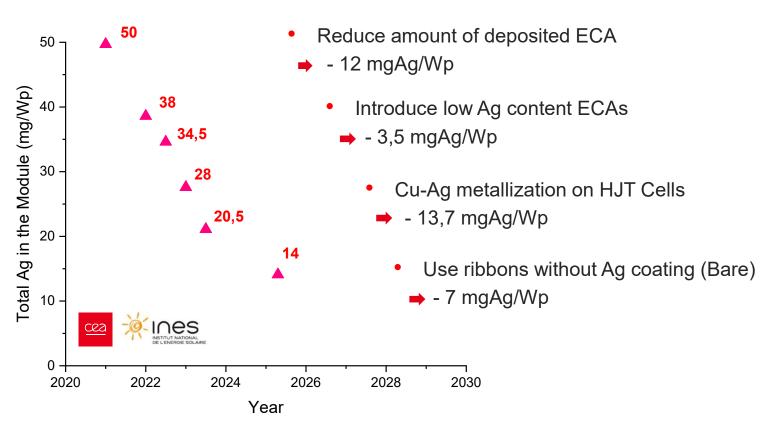






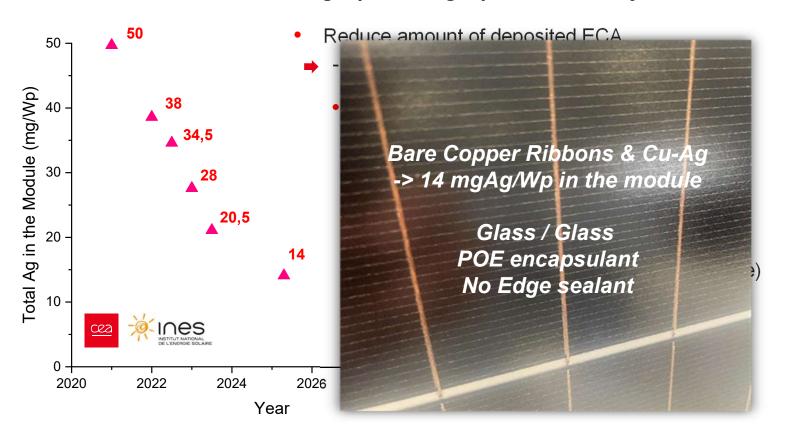
- 11 mgAg/Wp give a loss of 0.05 % absolute efficiency
- 7 mgAg/Wp is reachable but with a loss of 0.4 % of absolute efficiency with Cu-Ag Paste





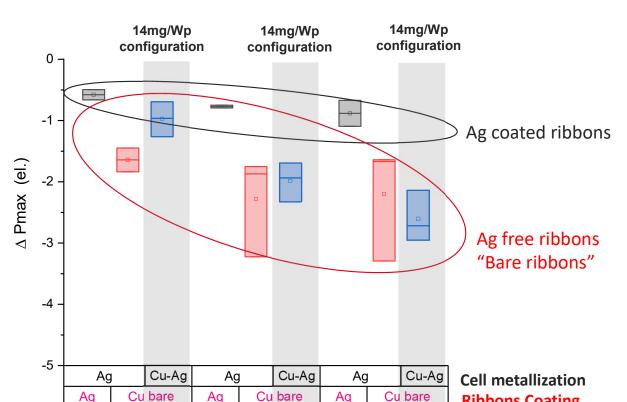








TC Ageing results



R.Monna & AI, Use of Cu ribbons and Cu-Ag HJT cell metallization on ECA based interconnection for PV modules, Solar Energy Materials and Solar Cells, Volume 287, 1 August 2025, 113594

Cu bare

400 CT

Ag

600 CT

Ribbons Coating

Number of TC

Ag



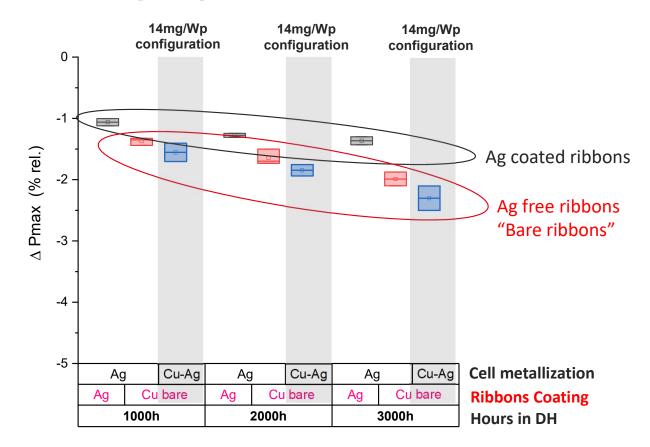
- The degradation is more pronounced on the modules with "bare ribbons"
- No difference observed between Ag and Cu-Ag Cell metallization
- Less than 3 % degradation after 600 TC
- Degradation only due to FF ○ No I_{sc} & V_{oc} change

Ag

200 CT

DH ageing results



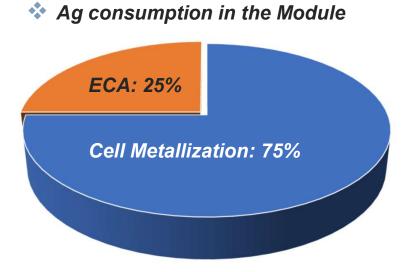


- ✓ The degradation is more pronounced on the modules with "bare ribbons"
- Cu-Ag Cell metallization seems to degrade a little bit more
- ✓ Less than 3 % degradation after 3000 h DH
- ✓ Degradation mainly due to FF
 Minor V_{oc} degradation

Combining Cu-Ag metallized cells with bare Cu ribbons allows to reach a **total Ag consumption in the**MODULE of 14 mg/Wp with a degradation of less than 3 % after 3000h DH and 600 TC

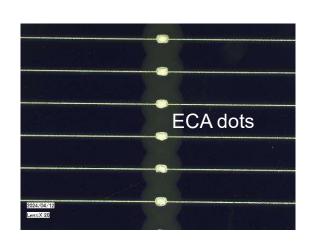
How can we decrease more the Ag consumption?

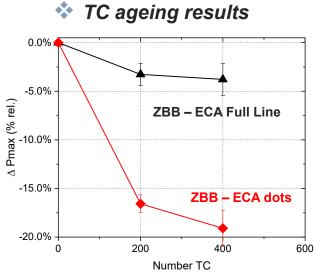
- ✓ ECA represent 25 % of the Ag consumption
 - Reduce the deposited weight -> ECA dots or pads
 - Reduce the amount of Silver in the ECA
- ✓ The cell represent more than 75%
 - Go to full Cu Cell metallization
 - o Introduce ZBB cells

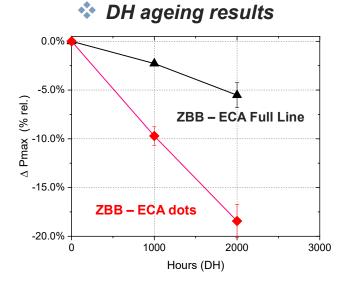


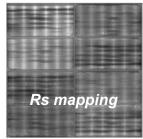
To ZBB interconnection

- ✓ Possibility to gain 1.1 mg/Wp with ZBB cells (Cu-Ag metallization)
- ✓ Possibility to gain 1.9 mg/Wp with ECA dots deposition







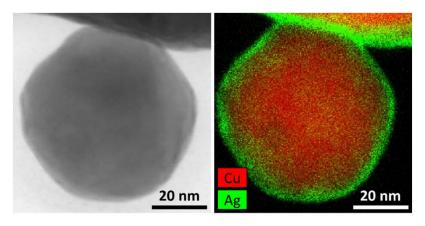


Significant power decrease (> 15%) with ECA dots on ZBB cells after thermal cycling and damp heat

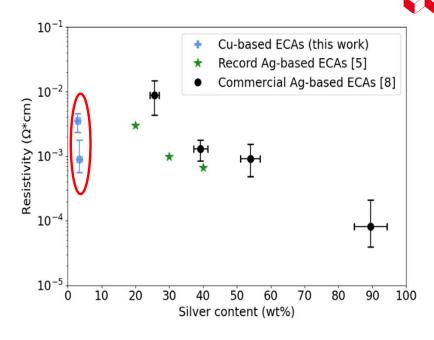
✓ Issue with pad alignment that increases series resistance

To Cu-based ECAs

Home-made Cu-Ag nanoparticles *



- ✓ Core-Shell copper-silver particles
- ✓ $T_{onset} = 178 \pm 2 \, ^{\circ}C$



- ✓ Resistivities from 3.5 x 10⁻³ to 9.0 x 10⁻⁴ Ω.cm comparable to commercial ECAs
- ✓ Ag content < 10 wt%

2.5 mgAg/Wp gain (ECA) Ageing tests on progress

^{*} Nathalie Ronayette & Al, Reduction of silver content in Electrically Conductive Adhesives for low-temperature interconnection of solar cells, Solar Energy Materials and Solar Cells, Volume 292, 15 October 2025, 113762



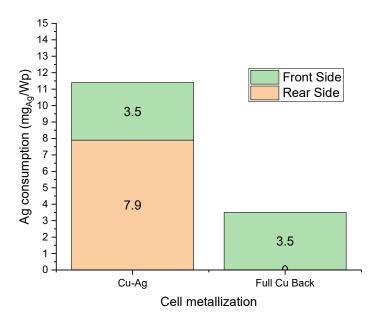
Rear Side Full Cu metallization as a strategy towards lower Ag consumption

* Full Copper on the Backside

- ✓ Front Side: Cu-Ag (~40 wt% Ag) screenprinting metallization
- ✓ Rear Side: Full Cu screen-printing metallization
 - Larger screen-opening for optimal results
 - Heating press used for Cu paste annealing

7 mgAg/Wp in the module with BARE Cu ribbons

* Ag consumption on the Cells

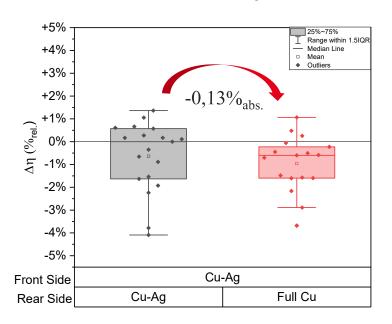


✓ 3.5 mgAg/Wp on the cell

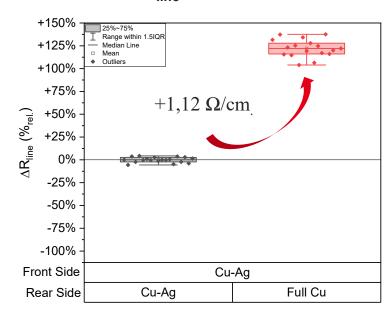


Rear Side Full Cu metallization as a strategy towards **lower Ag consumption**

Cell Efficiency



❖ R_{line} – Rear Side



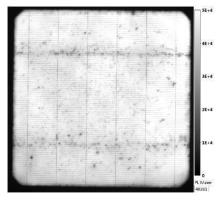
- Efficiency loss reduced to 0.13 % absolute / Cu-Ag metallization
- ✓ Increase of the line resistance on the backside



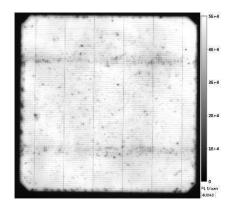
TCO as a barrier layer against Cu diffusion

- ▼ TCOs are well documented as a relatively effective barrier to Cu diffusion at moderate temperatures (≤ 300°C)
- ✓ No lifetime degradation observed after metallization annealing
- ✓ The long-term stability still needs to be investigated at the module level

❖ PL images



Cu-Ag Front & Back



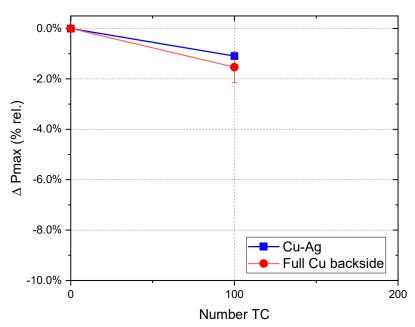
Full Cu Back

<u>cea</u>

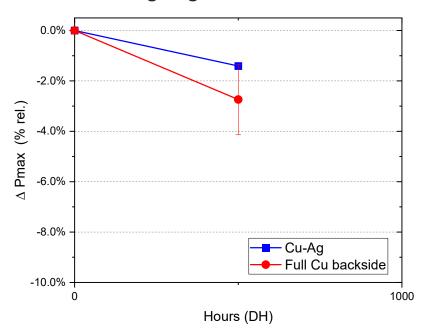


Rear Side Full Cu metallization as a strategy towards lower Ag consumption





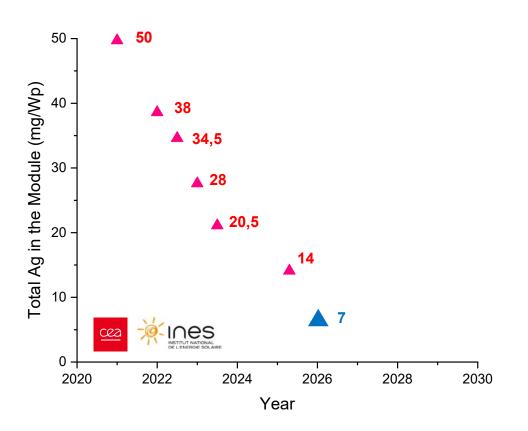
DH ageing results on modules



- ✓ Good results on CT ageing compared to our reference Cu-Ag
- ✓ Slightly elevated degradation after 500 hours of DH

Conclusion of the study

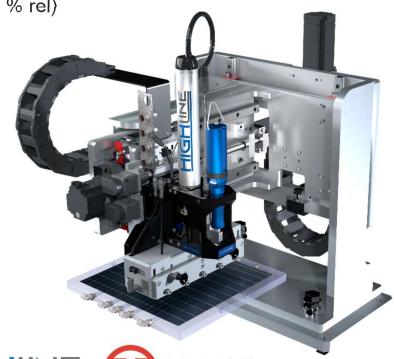




- ✓ 14 mgAg/Wp reached on module by interconnecting Cu-Ag metallized HJT cells with bare Cu ribbons and ECA
 - Less than 3 % degradation after 600 TC and after 3000 h DH (3x IEC passed)
- Significant power losses with ECA dots after thermal cycling and damp heat
 - Reducing silver consumption in the ECA should rather be achieved through a decrease in the Ag concentration in the ECA
- ✓ HJT cells with Full Cu metallization on the Backside
 - o 7 mg/Wp silver consumption in the module
 - Encouraging initial aging tests; Some issues in DH which has to be solved

Upcoming developments

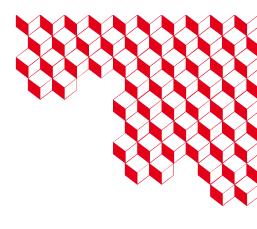
- ✓ Make reliable HJT modules with full Cu metallized Cells Edge Sealant will probably be necessary
- ✓ Front and Back 100 % Cu Cell metallization to obtain a consumption of 3 mg/Wp in the module
- ✓ Reduce electrical losses with Cu pastes and bare Cu ribbons (-2 % rel)
- ✓ Interconnexion with Wires (needs mechanical strengthening)
- ✓ Novel ECA deposition Cell stringing up to ½ G12 Cells
 - ✓ Put down ECA with the « Highline » dispensing head
 - Reduces ECA consumption: More than 15% reduction in material usage.
 - Increases throughput: More than 20% increase in throughput.
 - Versatility: Capable of handling various materials incl. emerging technologies
 - No contact with the cell -> Advantageous for Tandem Cells











Thank you



CEA-Liten, Grenoble, France

liten.cea.fr

remi.monna@cea.fr

T. + 33 (0) 479 792 931





